

Synthesis of Nano-Grained ZnWO4 Thin Film Scintillator by Thermal Evaporating Deposition Method

QBe

Quartz Glass

A) 700°C

Heon Yong Jeong, Ju Hyuk Lee, Jun Heo and Sung Oh Cho*

Department of Nuclear & Quantum Eng. Korea Advanced Institute of Science and Technology (KAIST),

Daejeon 305-701, Republic of Korea

*e-mail: socho@kaist.ac.kr

Introduction

High-resolution X-ray imaging system is composed of a scintillator and an optical detector coupled with lens. Spatial resolution is the one of most important parameters of high-resolution X-ray imaging. When this optical detector has an effective pixel size from nano to micro meter, X-ray images are developed with micron spatial resolution. However, spatial resolution of this system is affected by the structure of a scintillator because the optical detector coupled with lens is highly sensitive to the optical diffusion phenomenon caused by the scintillator structure.

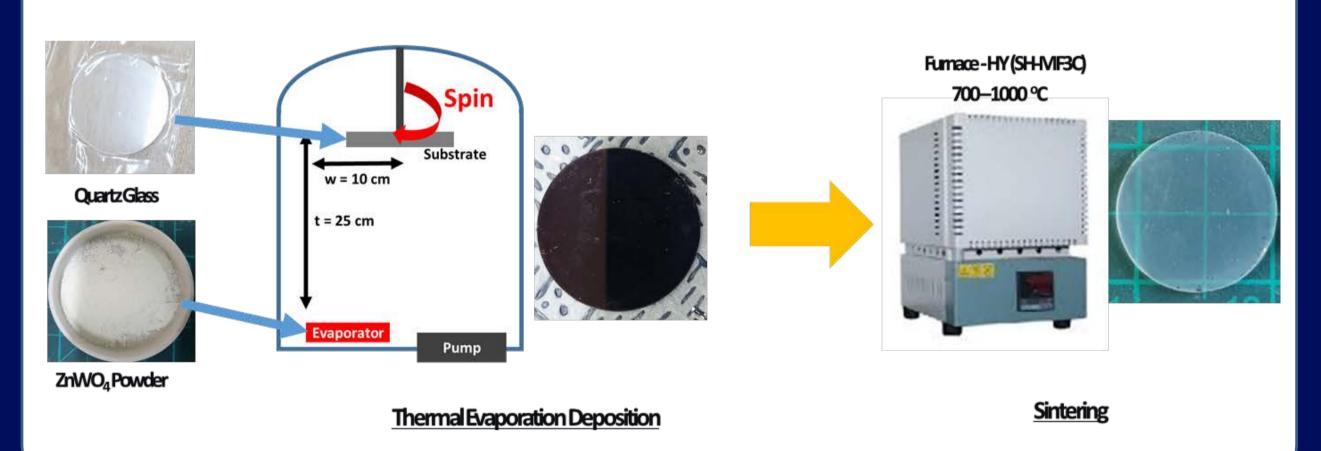
In this study, nano-grained zinc tungstate (ZnWO4) was used for the thin-layer transparent film scintillator on quartz glass using the thermal evaporating deposition method. ZnWO4 has been used for a long time as an X-ray scintillator. [1] For this reason, ZnWO4 has 2.3 times more luminescence characteristics under X-ray irradiation than commonly used Bi4Ge3O12 (BGO). [2] In addition, the material is high density ($\rho = 7.87$ g/cm3), high effective atomic number (Zeff = 61), short decay time, high stability and economical price. [3] Since ZnWO4 has high X-ray absorption capability relative to ρ Z4eff, it has the potential to be utilized in thin film scintillators used for high-resolution X-ray imaging. ZnWO4 can be easily utilized in the thermal evaporating deposition method because it has a relatively low melting point (~1166 °C). [1] For the above reasons, we demonstrated that thermal evaporating deposition method can easily fabricate thin-layer transparent nano-grained ZnWO4 film.

Experimental

• Fabrication of ZnWO₄ Powder

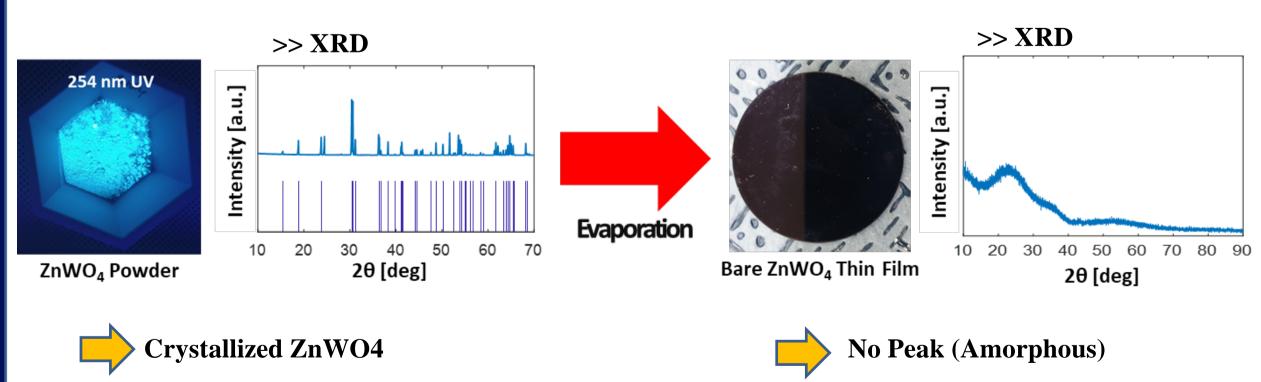


• Fabrication of Transparent ZnWO₄ Thin Film

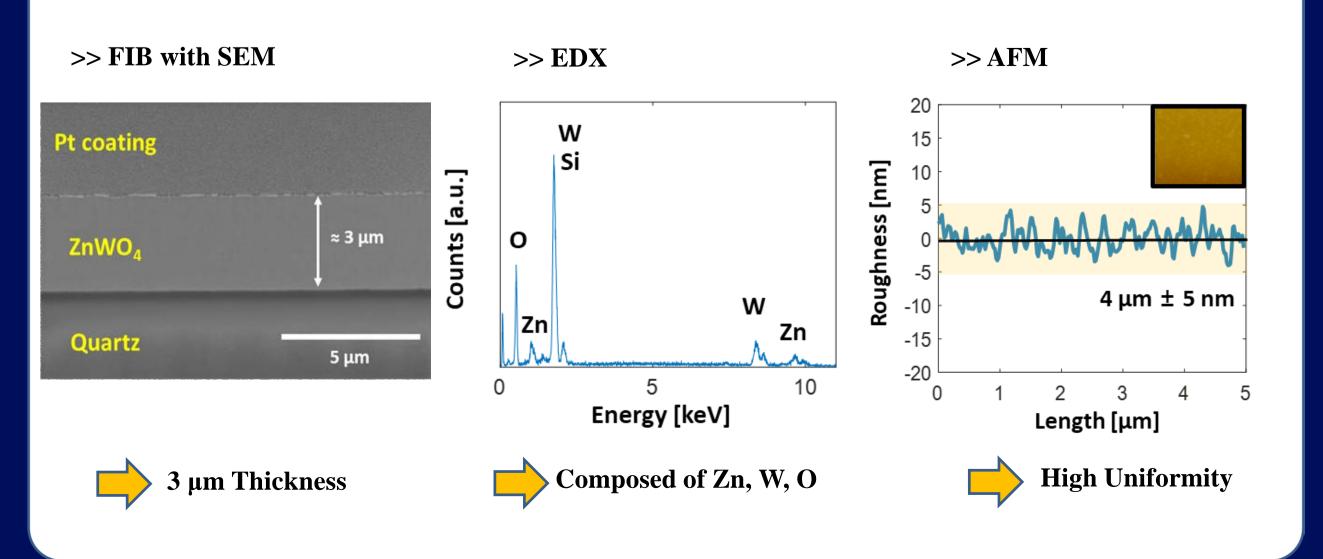


Results

• Thermal Evaporating Deposition

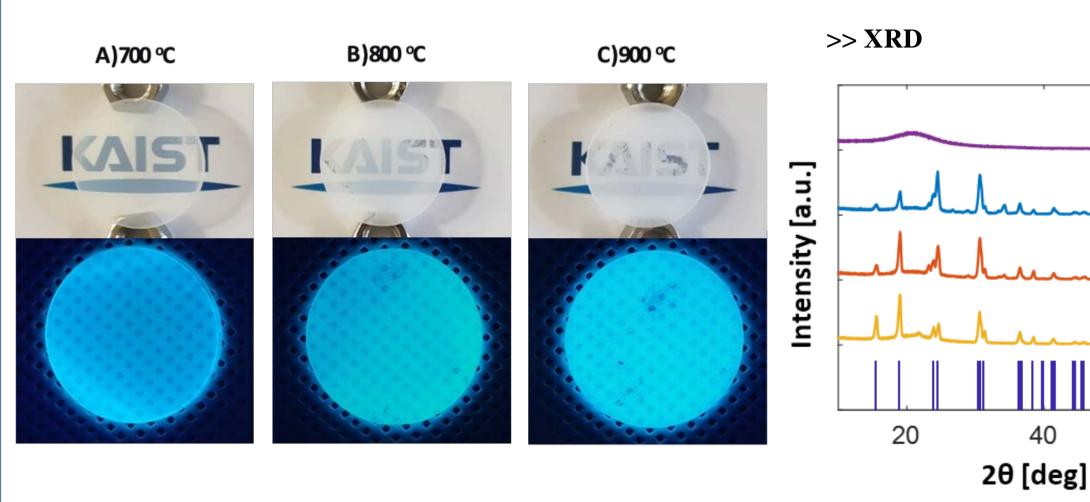


• Characterization of Evaporated ZnWO₄ Thin Film

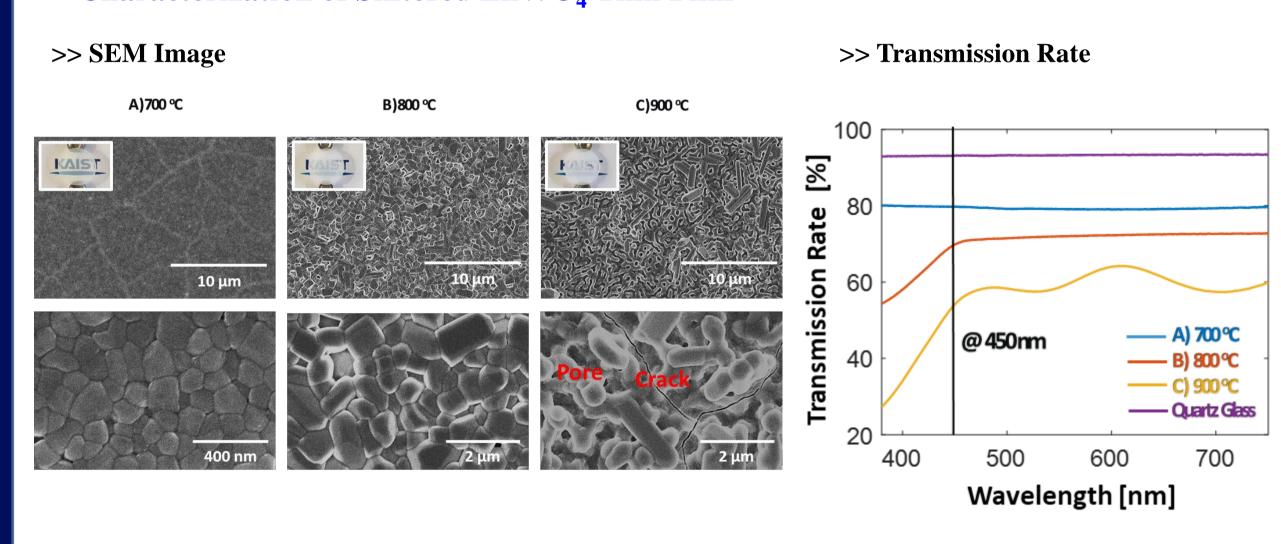


Results

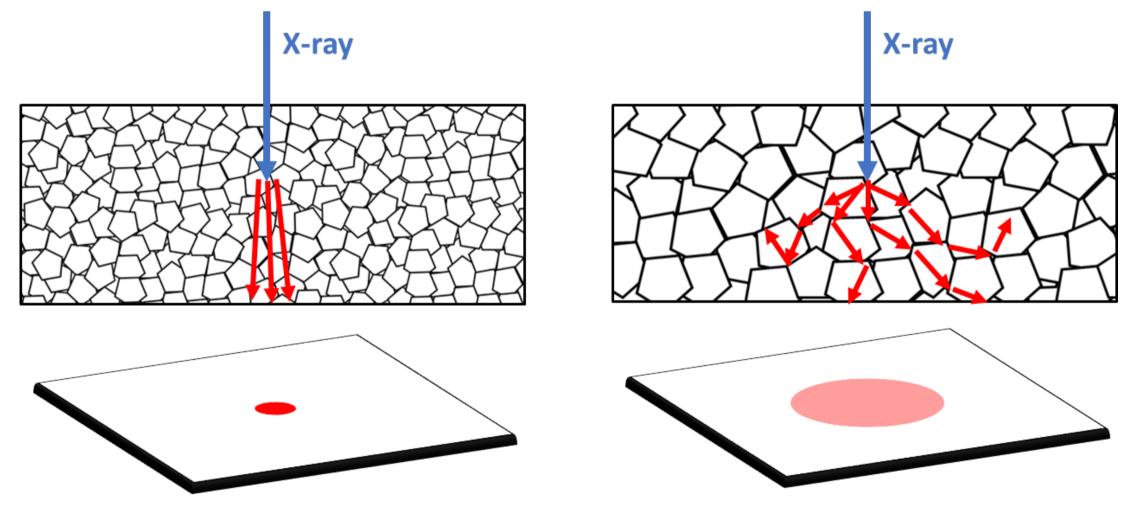
• Sintered ZnWO₄ Thin Film



• Characterization of Sintered ZnWO₄ Thin Film



• The effect of Grain Size of scintillator in X-ray Imaging



Smaller Grained Scintillator→ Higher Spatial Resolution X-ray Image

Conclusion

We have demonstrated nano-grained thin-layer transparent film can be fabricated by thermal evaporating deposition method. Since it has a nano-grained structure, mie-scattering for optical light is minimized. Therefore, the optimized ZnWO4 scintillator film has high optical property. These results indicated that nano-grained ZnWO4 thin flm scintllator fabricated by thermal evaporating deposition method is expected to be used effectively in the field of high-resolution X-ray imaging.





Reference

[1] Touš, J.; Blažek, K.; Pína, L.; Sopko, B. High-resolution X-ray imaging CCD camera based on a thin scintillator screen. Radiation measurements 2007, 42, 925-928.

[2] Touš, J.; Horvath, M.; Pína, L.; Blažek, K.; Sopko, B. High-resolution application of YAG: Ce and LuAG: Ce imaging detectors with a CCD X-ray camera. Nuclear Instruments and Methods in Physics Research Section A: Accelerators, Spectrometers, Detectors and Associated Equipment 2008, 591, 264-267.

[3] Buryi, M.; Laguta, V.; Nikl, M.; Gorbenko, V.; Zorenko, T.; Zorenko, Y. LPE growth and study of the Ce 3+ incorporation in LuAlO 3: Ce single crystalline film scintillators. CrystEngComm 2019, 21, 3313-3321.

of ZnWO4 and Eutectics ZnO/ZnWO4